

Investigation of Whisker Formation on Tin Plated Conductors

1. SCOPE:

This SAE Aerospace Information Report (AIR) shall be limited to general information about tin whisker formation on tin plated conductors. It summarizes the mechanisms of metal whisker formation and describes possible conclusions as related to tin plated conductors. It also provides a number of reference documents that describes research and observations of the whisker phenomena, recommendations to prevent its formation and conclusions.

The investigation by this task group of AE-8D was initiated by a request of the Naval Air Warfare Center, Indianapolis, Indiana, to determine if the phenomenon of tin whiskers is a problem in aerospace wire and cable.

1.1 Purpose:

This document provides some brief information about tin whisker formation and a list of reference documents that can provide more detailed information.

2. APPLICABLE REFERENCES:

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### 3. GENERAL:

#### 3.1 Background:

Whiskers are metal filaments having a diameter of the order of  $1\ \mu\text{m}$  ( $10^{-4}\ \text{cm}$ ), although they have been observed as small as  $6\ \text{nm}$  ( $10^{-7}\ \text{cm}$ ) and as large as  $6\ \mu\text{m}$ . Tin whiskers have been measured in excess of  $2.5\ \text{mm}$  in length and can conduct electrical current in excess of  $32\ \text{mA}$ . Whiskers generally grow straight from the substrate, however some curved examples have been reported.

Documented research of whisker formation in metals dates back to the mid 1940's. One of the earliest observations of whisker formation was during an investigation for electrical failure in densely packed electronic assemblies. It was observed that conductive zinc filaments had bridged across the spacing between components causing failures. Whiskers have the potential of causing short circuit failures in low voltage, low current circuits as a current path of a few milliamperes can seriously affect these systems. Conversely, whiskers do not seem to affect high voltage, high current circuits as the filaments simply "burn out" if they cause a short.

Later investigation revealed that other metals such as cadmium and especially tin was susceptible to whisker growth. Whisker growth has only been observed to form on pure metal surfaces. Tin whiskers can develop on solid tin, tin plating that is applied by electrodeposition or evaporation, fused tin coatings, reflowed tin, etc.

#### 3.2 Whisker Composition and Structure:

As whiskers grow from the pure metal surface, they retain the same composition and have been analyzed to be single crystal in structure.

#### 3.3 Whisker Growth Mechanism:

The growth of tin whiskers has been investigated and documented by several researchers, however, there are no definitive theories regarding the growth mechanism, conditions necessary, prediction of growth sites, or methods to completely prevent its formation.

Observations have shown that whiskers grow from their base outward. There seems to be a general consensus that diffusion and mechanical stress are related to nucleation and rate of growth.

However, many observations of whiskers have shown no depressions or depletion of the tin surface surrounding the filament which may indicate more than localized diffusion. Controlled experiments varying the amount of stress application, both tensile and compressive, has shown varying results. Therefore, confirmation of localized stress affecting whisker formation has not been established.

### 3.4 Mechanisms That Affect Whisker Growth:

Surface composition has been observed to affect the number and rate of whisker growth. On tin surfaces, lead alloyed in a few percent with the tin has greatly reduced the nucleation sites for whiskers. Other alloying elements such as antimony, cobalt, copper, germanium, gold and nickel have similar effects.

Mechanical barriers such as coatings can also affect whisker growth. Thin barriers such as chromate coatings, oils, greases, silicones, waxes and thin lacquer coatings do not prevent whisker growth. Thicker barriers such as resin coatings greater than 1/16 in or more have successfully prevented whisker growth.

### 3.5 Variability of Whisker Growth:

Most of the researchers performing investigative work on the subject of whiskers have experienced one common conclusion, that whisker formation is not consistent or predictable. Experiments have resulted in the extremes of rapid whisker growth after a short period of time to no visible growth after extended periods on different samples prepared under similar conditions. Variations in temperature and humidity conditions has shown both increased growth rate and no effect.

## 4. DISCUSSION:

### 4.1 Whisker Growth on Tin Coated Copper Conductors:

In industry, the occurrence of tin whisker growth is a concern in electronic equipment containing exposed tin coated surfaces such as printed circuit boards, chassis components, and connector terminations. Under these circumstances, the phenomena of whisker formation has been well documented and recommendations have been presented by many researchers to eliminate its growth.

There have been several instances of whisker growth on tin plated copper conductor. These instances have been limited to bus wire applications where the conductor had no surface insulation.

No documented observations of tin whisker growth on insulated tin plated copper wire was found in published literature.

The SAE AE-8D subcommittee was surveyed requesting information and known cases or problems caused by tin whisker formation on wire and cable. Of the 19 respondents:

- a. 8 had prior knowledge of the tin whisker phenomenon
- b. 1 had references to literature
- c. NO respondents had direct information on cases of whiskers in wire and cable

5. HYPOTHESES:

5.1 Insulation as a Barrier:

It is conceivable that the insulation placed on tin plated copper conductor serves as an effective barrier to whisker formation. Therefore, if conditions are conducive for whisker formation, it would be limited to exposed areas where the insulation has been stripped, such as conductor strand surfaces adjacent to a termination.

5.2 Limited Free Tin on Tin Coated Conductors:

Tin coated copper conductors usually contain a relatively thin coating of electroplated tin on the surface of the conductor strands. It is a well documented phenomena that diffusion of copper and tin forms a copper-tin intermetallic that eventually consumes all the free tin on the conductor surface. This is also characterized by the loss of solderability of tin plated copper wire after time. It is conceivable that this change in composition of the surface from pure tin to intermetallic tin effectively removes the conditions necessary for whiskers to form.

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APPENDIX A

A.1 SCANNING ELECTRON MICROSCOPE IMAGES OF TIN WHISKERS:

The SEM images were reproduced with the permission of Lockheed Martin Astronautics, Denver, CO (see Figure A1).

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